

High-resolution X-ray diffraction study of (001)-oriented SnTe and $Pb_{1-x}Sn_xTe$ layers, MBE-grown on commercial GaAs substrate

Adrian Sulich^{1,*}, Krzysztof Dybko^{1,2}, Wojciech Wołkanowicz¹, Elżbieta Łusakowska¹, Piotr Dziawa¹, Janusz Sadowski¹, Badri Taliashvili¹, Tomasz Wojtowicz², Tomasz Story^{1,2}, and Jarosław Z. Domagała¹



¹ Institute of Physics, Polish Academy of Sciences, Aleja Lotników 32/46, PL 02 668 Warsaw, Poland

² International Research Centre MagTop, Institute of Physics, Polish Academy of Sciences, Aleja Lotników 32/46, PL 02 668 Warsaw, Poland

* Corresponding author, e-mail: sulich@ifpan.edu.pl

Introduction

SnTe-related alloys, compounds and nanostructures are promising and currently investigated candidate materials for topological crystalline insulators or semimetals, as well as thermoelectrics or superconductors [1-5]. Some of their crucial properties are protected by crystal symmetry thus it is important to study their crystallographic quality, extended defects amount and spatial distribution, lattice strain and chemical homogeneity.

Comprehensive structural characterization of (001)-oriented SnTe and $Pb_{1-x}Sn_xTe$ layers deposited on commercial GaAs substrate with special CdTe(001) buffer layer was performed using laboratory high-resolution X-ray diffractometer equipped with $CuK_{\alpha 1}$ irradiation ($\lambda = 1.5404 \text{ \AA}$).

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 [3] A.S. Tarasov et al., Applied Surface Science, 569 (2021) 150930.
 [4] A. Sulich et al., Journal of Materials Chemistry C, 10 (2022) 3139.
 [5] S. Dad et al., Scientific Reports 14.1 (2024) 589.

Summary

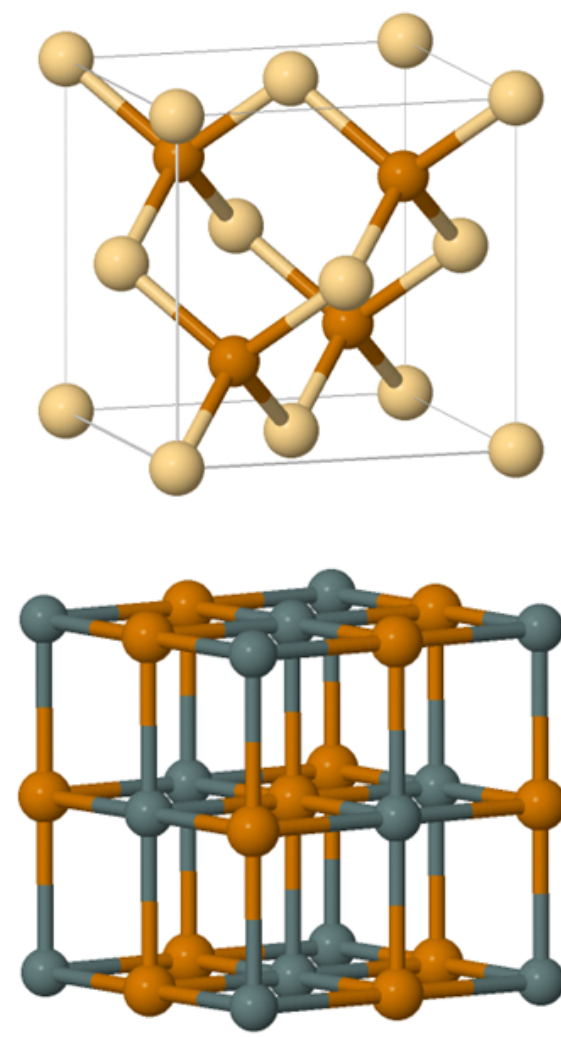
- Crystallographic quality of the characterized materials is good (the values of FWHM of X-ray diffraction curves measured by us are comparable with published in literature);
- Although CdTe buffer is fully relaxed in all of the samples, SnTe and $Pb_{1-x}Sn_xTe$ layers are partially strained (the minimal percentage relaxation is 86% and the maximal 98%);
- The following types of defects have been detected in CdTe, $Pb_{1-x}Sn_xTe$ and SnTe: distortion of the unit cells, misfit dislocations presence and misorientation between the substrate and the layers: CdTe-GaAs, SnTe-CdTe and $Pb_{1-x}Sn_xTe$ -CdTe;
- Azimuthal defects distribution in all of the studied layers is anisotropic;
- Unit cell distortion in $Pb_{1-x}Sn_xTe$ is tetragonal but in some SnTe layers alternative, monoclinic distortion occurs which may affect the topological properties of the heterostructure (SnTe lattice strain $\sim 10^{-3}$ is large enough to open an energy gap in topological surface states, secured by the crystal symmetry).

Unit cells of GaAs, CdTe, SnTe and PbTe

Heterostructure's scheme

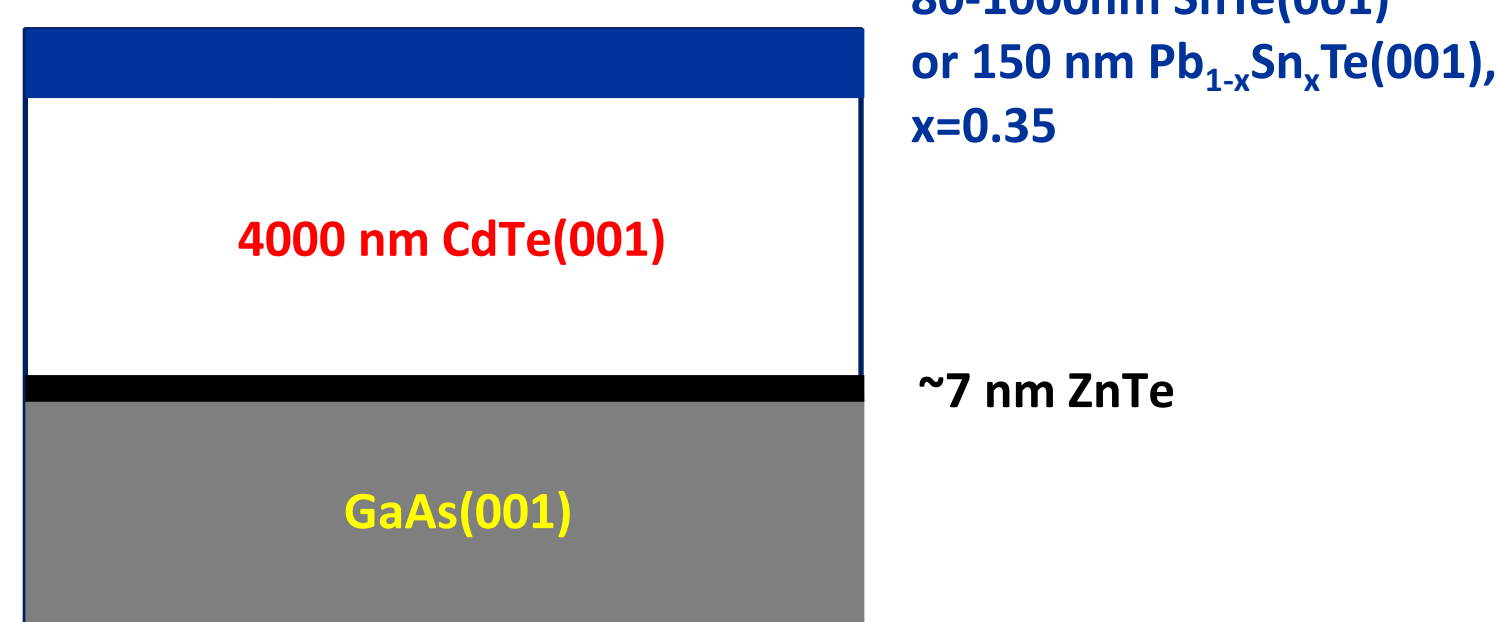
GaAs(001) substrate's scheme

GaAs-CdTe interface: crystallographic planes misorientation

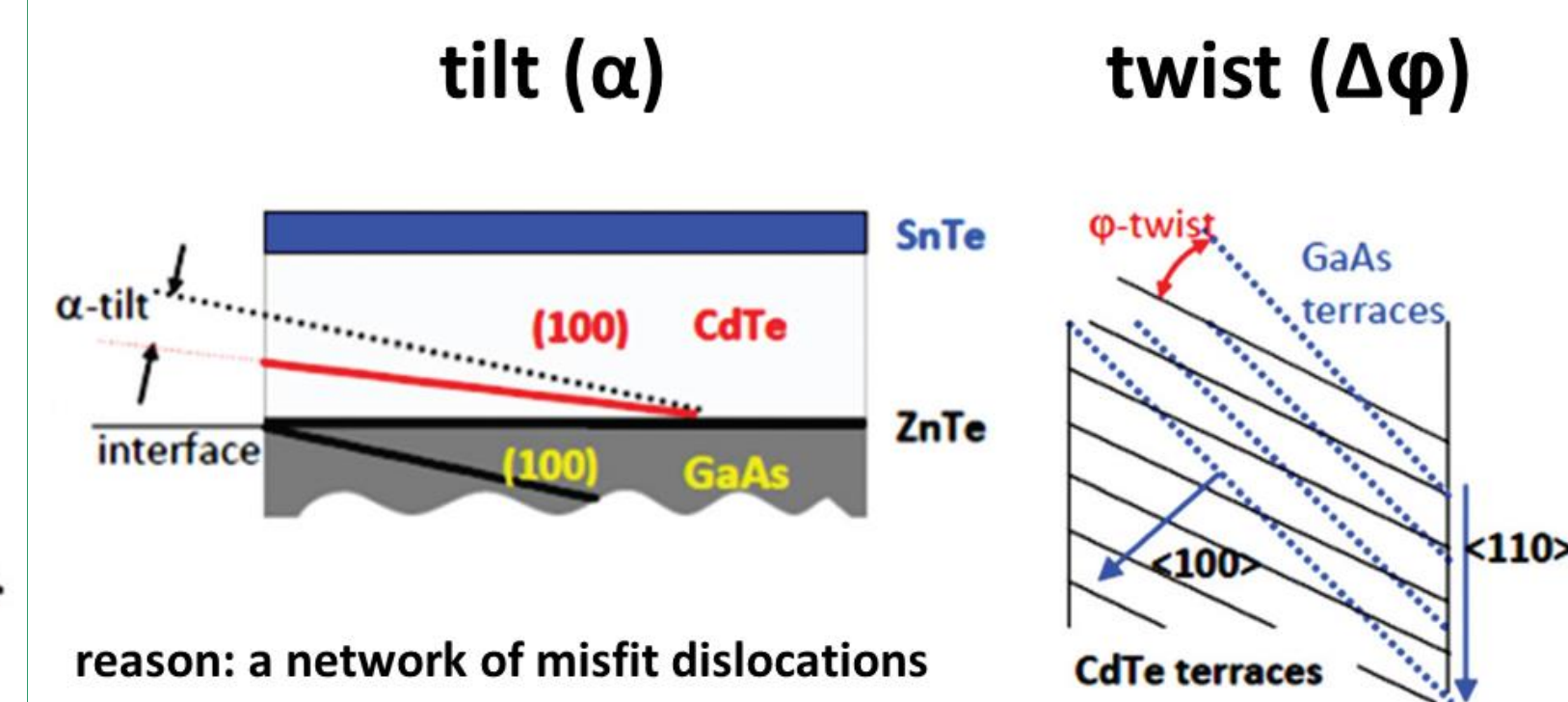
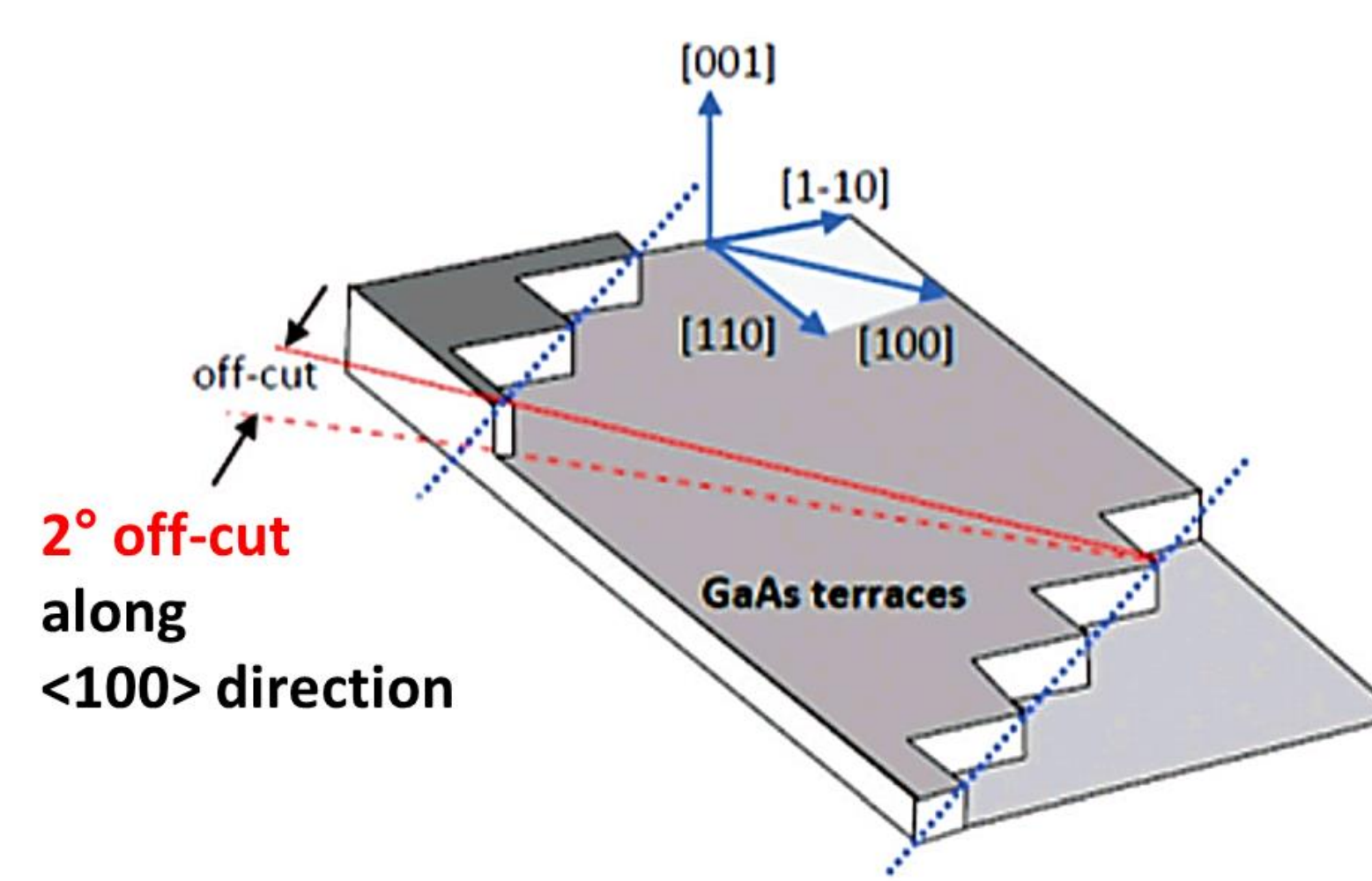


zinc-blende structure
 GaAs:
 $a = 5.6535 \text{ \AA}$
 CdTe:
 $a = 6.480 \text{ \AA}$

rock-salt structure
 SnTe and $Pb_{1-x}Sn_xTe$:
 $a (\text{SnTe}) = 6.300 \text{ \AA}$
 $a (\text{PbTe}) = 6.460 \text{ \AA}$



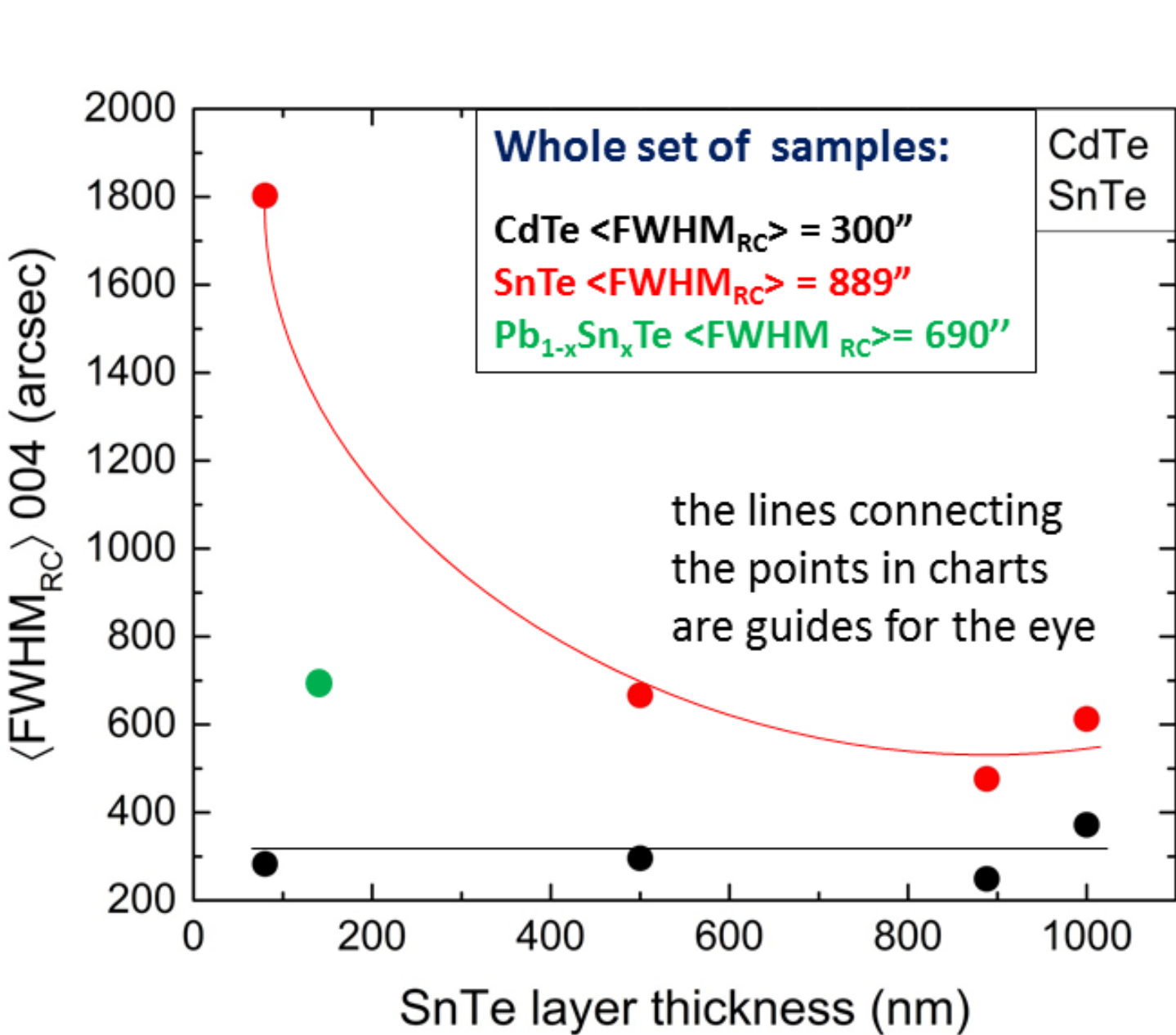
Growth technique: Molecular Beam Epitaxy



General crystallographic quality of the samples

SnTe unit cell distortion magnitude and order

SnTe unit cell distortion magnitude and order

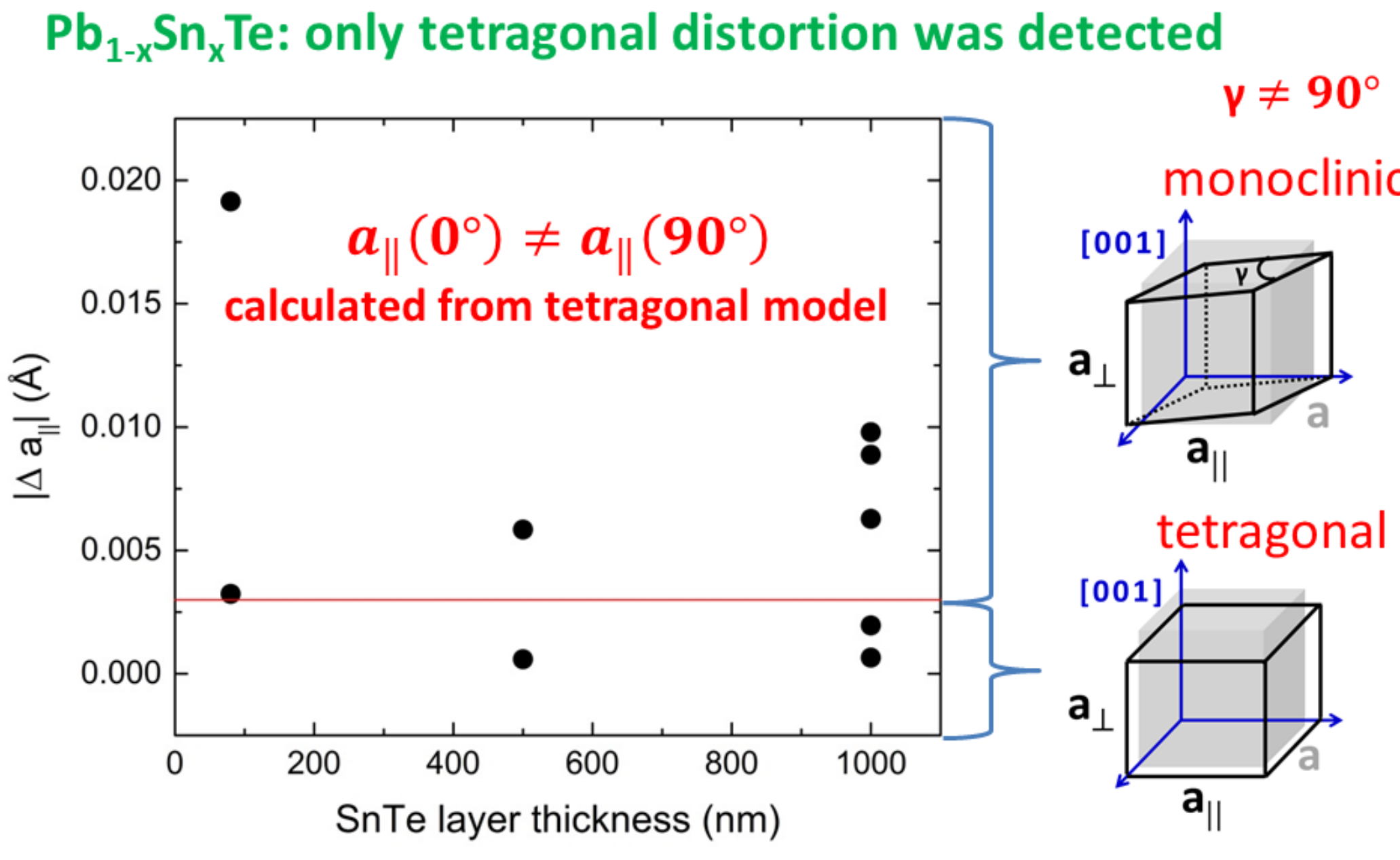
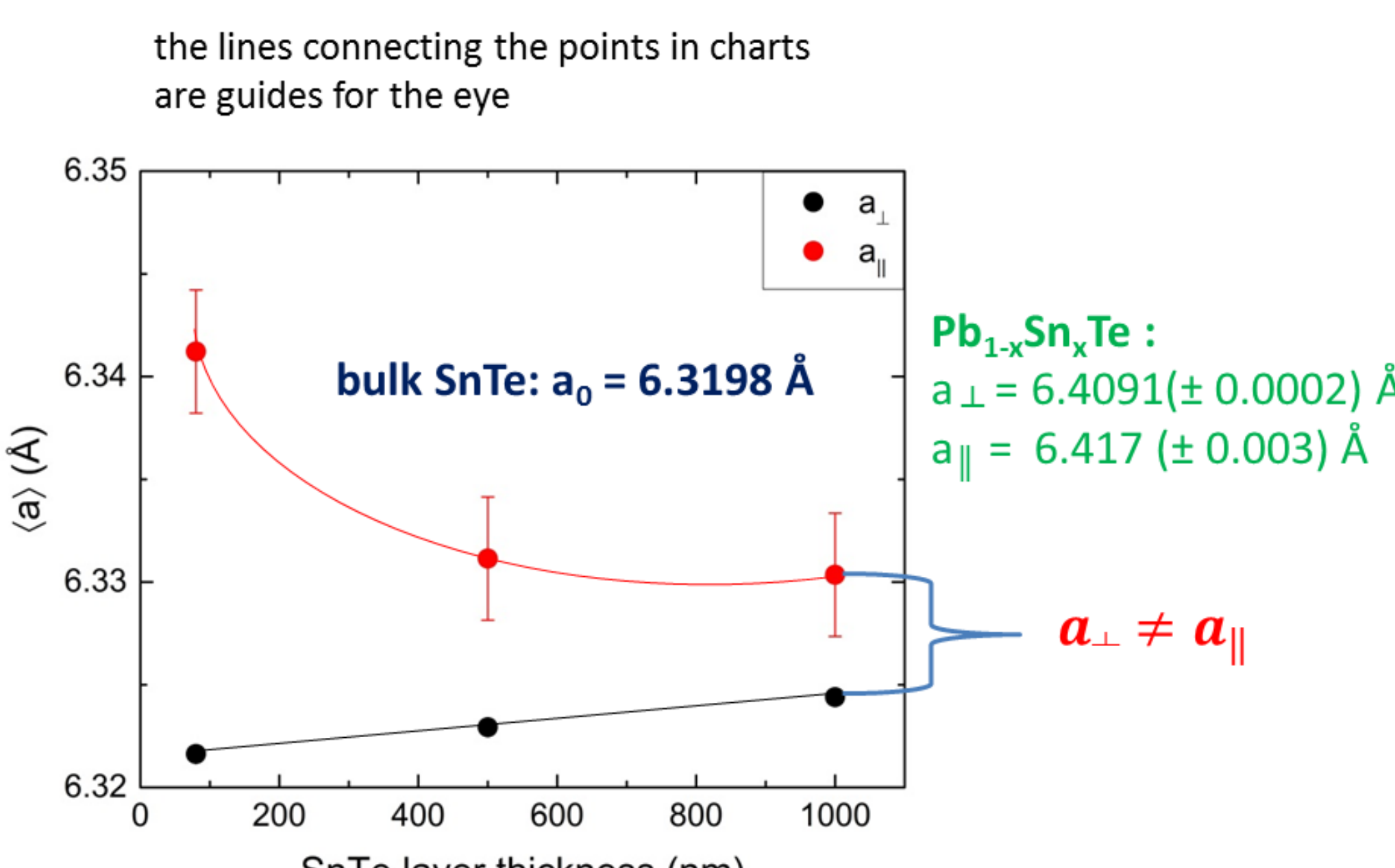


(001) plane misorientation

CdTe-GaAs :
 tilt: up to 0.8°
 twist: up to 23°

SnTe-CdTe :
 tilt: up to 0.12°
 twist: up to 2°

$Pb_{1-x}Sn_xTe$ -CdTe :
 tilt: 0.29°
 twist: 0.09°



Impact of a SnTe layer thickness on horizontal strain magnitude in SnTe

Impact of a SnTe layer thickness on horizontal strain relaxation in SnTe

Azimuthal defects distribution in CdTe and SnTe

